

Machine learning potentials enabling realistic-size simulation and accelerated material discovery

Seungwu Han

*Department of Materials Science and Engineering, Seoul National University,
Seoul 08826, South Korea
hansw@snu.ac.kr*

Recently, machine-learning (ML) approaches to developing interatomic potentials are attracting considerable attention because it is poised to overcome the major shortcoming inherent to the classical potential and density functional theory (DFT), i.e., difficulty in potential development and huge computational cost, respectively. In particular, the high-dimensional neural network potential (NNP) suggested by Behler and Parrinello is attracting wide interests with applications demonstrated over various materials. In this presentation, we first introduce our in-house code for training and executing NNP called SIMPLE-NN (SNU Interatomic Machine-learning Potential package-version Neural Network) [1] and discuss its unique feature such as GDF weighting [2] which significantly improves stability of ML potentials during MD simulations. We further discuss on the fundamental aspect of ML potentials that enables the transferability of the potential.[3] We show that the ML potential is nothing but a manifestation of O(N) method of DFT, which is realized in terms of atomic energies.

As application examples, we present our recent results on phase change behavior of chalcogenides [4] and silicidation process [5] in semiconductor fabrication. Furthermore, we will show that ML potentials can be used as highly accurate surrogate models in exploring large space of crystal structures [6]. This enables finding the stable crystal structure for complicated multicomponent systems. [7]

[1] K. Lee et al, *Comp. Phys. Comm.*, **242**, 95 (2019).

[2] W. Jeong et al, *J. Phys. Chem. C*, **122**, 22790 (2018).

[3] D. Yoo et al, *Phys. Rev. Mater.*, **78**, 093802 (2019).

[4] D. Lee et al, *Comp. Mater. Sci.*, **181**, 109725 (2020).

[5] W. Jeong et al, *J. Phys. Chem. Lett.*, **11**, 6090 (2020).

[6] C. Hong et al, *Phys. Rev. B*, **102**, 224104 (2020)

[7] S. Kang et al, in preparation.